	Application No.	Applicant(s)
Notice of Allowability		STALMANS et al.
	10/644,690 Examiner	Art Unit
	Lee, Calvin	2825
Th MAILING DATE of this communication app I claims being allowable, PROSECUTION ON THE MERITS IS rewith (or previously mailed), a Notice of Allowance (PTOL-85 DTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT F the Office or upon petition by the applicant. See 37 CFR 1.31	S (OR REMAINS) CLOSED in it is on their appropriate communities. This application is sugard and MPEP 1308.	this application. If not included inication will be mailed in due course. THIS
This communication is responsive to <u>Telephone Interview</u>	<u>dated June 22, 2004</u> .	
☑ The allowed claim(s) is/are <u>1-6 and 8-23</u> .		
igotimes The drawings filed on 19 August 2003 are accepted by the	e Examiner.	
 Acknowledgment is made of a claim for foreign priority unalling. a) ☐ All b) ☐ Some* c) ☐ None of the: 1. ☐ Certified copies of the priority documents have 2. ☐ Certified copies of the priority documents have 3. ☐ Copies of the certified copies of the priority documents. 	re been received. re been received in Applicatio	n No
International Bureau (PCT Rule 17.2(a)).		
* Certified copies not received:		
Applicant has THREE MONTHS FROM THE "MAILING DATE" noted below. Failure to timely comply will result in ABANDON! THIS THREE-MONTH PERIOD IS NOT EXTENDABLE.		a reply complying with the requirements
☐ A SUBSTITUTE OATH OR DECLARATION must be subn INFORMAL PATENT APPLICATION (PTO-152) which giv		
CORRECTED DRAWINGS (as "replacement sheets") mu		
(a) including changes required by the Notice of Draftsper		v (PTO-948) attached
1) hereto or 2) to Paper No./Mail Date		in the Office setting of
(b) ☐ including changes required by the attached Examiner Paper No./Mail Date	's Amendment / Comment or	In the Office action of
Identifying indicia such as the application number (see 37 CFR each sheet. Replacement sheet(s) should be labeled as such in	1.84(c)) should be written on th the header according to 37 CF	ne drawings in the front (not the back) of R 1.121(d).
DEPOSIT OF and/or INFORMATION about the deposit attached Examiner's comment regarding REQUIREMENT		
	5. ☐ Notice of Inf	formal Patent Application (PTO-152)
☐ Notice of References Cited (PTO-892)	6. ⊠ Interview Su	formal Patent Application (PTO-152) ummary (PTO-413), Mail Date <i>hereto</i>
 Notice of References Cited (PTO-892) Notice of Draftperson's Patent Drawing Review (PTO-948) Information Disclosure Statements (PTO-1449 or PTO/SB/ 	6. ⊠ Interview St Paper No./	, , , , , , , , , , , , , , , , , , , ,
tachm nt(s) ☐ Notice of References Cited (PTO-892) ☐ Notice of Draftperson's Patent Drawing Review (PTO-948) ☐ Information Disclosure Statements (PTO-1449 or PTO/SB/Paper No./Mail Date ☐ Examiner's Comment Regarding Requirement for Deposit of Biological Material	6. ⊠ Interview St Paper No./ 08), 7. ⊠ Examiner's	ummary (PTO-413), Mail Date <u>hereto</u> . Amendment/Comment Statement of Reasons for Allowance

Application No: 10/644,690 Page 2
Docket No: IMEC232.001DV1 STALMANS et al.

OFFICE ACTION

Examiner's Amendment

1. An examiner's amendment to the record appears below. Should the changes and/or additions be unacceptable to applicant, an amendment may be filed as provided by 37 CFR 1.312 IN THE CLAIMS:

Claim 1, line 6, after "a light reflector" inserted --wherein the porous silicon layer formed comprises porous silicon parts and columnar conductive parts, said columnar conductive parts forming conductive connections between the substrate and a first region of a semiconductive region-Claim 7 has been canceled.

Claim 8, line 1, replaced "recited in claim 7" with --recited in claim 1--

- 2. Authorization for this examiner's amendment was given in a telephone interview with Richard E. Campbell on June 22, 2004.
- 3. After the conversation, the examiner has found two minor informalities such as: Page 1, line 11, after "April 9, 2001" inserted --and issued as US Patent 6,683,367, -- Page 12 line 31, replaced "is this way" with --in this way-- Page 14 line 13, replaced "a epi-on-porous" with --an epi-on-porous--

Allowable Subject Matter

4. Claims 1-6 and 8-23 are allowed because US 6,194,245 to Tayanaka does not teach, *inter alia*, that a porous silicon layer formed comprises porous silicon parts and columnar conductive parts, and prior to the formation of a porous silicon layer a patterned mask layer is formed on a substrate to thereby define first and second areas.

Any inquiry concerning this communication from the Examiner should be directed to *Calvin Lee* at (571) 272-1896, Monday to Thursday, from 7 to 5 (ET). If attempts to reach the examiner by telephone are unsuccessful, Art Unit 2825's Supervisory Patent Examiner *Matthew Smith* whose telephone number is (571) 272-1907.

Any inquiry relating to the status of this application should be directed to the Group receptionist whose telephone number is (703) 308-0596. The fax phones are (703) 872-9318 for regular communications and (703) 872-9319 for After-Final communications.

MATTHEW SMITH
SUPERVISORY PATENT EXAMINER
TECHNOLOGY CENTER 2800

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June 23, 2004